Special Issue

Advances in Thin Film Transistors: Properties and Applications, 2nd Edition

Message from the Guest Editors

Recently, transparent oxide semiconductors (TOSs) have been the object of extensive research in various connected fields. Owing to their advantages of high mobility, good transparency, and ideal uniformity, TOSs are more suitable for the application of thin-film transistors (TFTs) than conventional Si TFTs. In addition, the features of a low-temperature process and their compatibility with flexible electronics enable TOSs to become the mainstream channel materials in nextgeneration flat panel displays, such as active-matrix liquid crystal displays (AMLCDs) and active-matrix organic light-emitting diodes (AMOLEDs). Both In2O3 (~3.7 eV) and Ga2O3 (~4.9 eV) with wide energy band gaps possess excellent transparency. By adjusting to each stoichiometry, indium-based transparent conducting oxide materials have been widely used in flat panel displays and optoelectronic devices, among other applications. Thin-film transistors (TFTs) have been in extensive use as on/off switch and current driving devices for various applications, ever since the concept of TFTs was reported. This Special Issue aims to cover recent advances in TFT technologies.

Guest Editors

Dr. Sheng-Po Chang

Dr. Kuan-Jen Chen

Dr. Chih-Chiang Yang

Dr. Ke-Jing Lee

Deadline for manuscript submissions

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Coatings
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
coatings@mdpi.com

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Now more than ever, research is asked to deliver knowledge and technologies to solve the major challenges faced by our society. The development of new materials and devices for (without the ambition to be exhaustive) energy, health and food technology, together with the need for establishing processes that reduce the impact on critical resources and the environment, is indeed in the spotlight of most contemporary research. Surface science and engineering play a key role in this regard, with an incredible potential in delivering new and deep scientific understanding and technical solutions essential to solve most of the major societal challenges.

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State Key Laboratory of New Ceramics and Fine Processing, School of Materials Science & Engineering, Tsinghua University, Beijing 100084, China

Dr. Emerson Coy

NanoBioMedical Centre, Adam Mickiewicz University in Poznań, ul. Wszechnicy Piastowskiej 3, 61-614 Poznań, Poland

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